Form PTO 1449 (Modified)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY DOCKET NO.		SERIAL NO.		
				295727US0PCT	10/594,282			
LIST OF	REFE	RENCES CITED BY AF	PLICANT	APPLICANT				
2101 01		NENGES CITED BY A	PEICANT	Hirotoshi ISHII, et al.				
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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE	
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	AW	Osamu HABA, et al., "A New Photoresist Based on Calix [4] resorcinarene Dendrimer", CHEMISTRY OF MATERIALS, VOI 11, No. 2, XP-002470141, 1999, pages 427-432						
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Examiner						Date Considered		
*Examiner: In conformance	itial if re	eference is considered, t considered. Include co	whether or not	citation is in conformance with MPEF with next communication to applicant	P 609; Draw lin	e through o	sitation if not in	